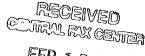
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251 North Avenue West, 2nd Floor Westfield, NJ 07090

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FEB 1 7 2004



To:	Com	missioner for Paten	ts	From:	David Bonham (703) 433-0510
Fax:	703-	872-9310		Total pages	: 13
Phone:				Date:	2/17/2004
Re:	In connection with prosecution in Serial. No. 09/905,172, please find enclosed an Amendment and Response to the Office Action mailed November 14, 2003.			t CC:	:
	David Bonham				
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Serial No. 09/905,172

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE,

Applicant:

David S. Mui et al.

Serial No.:

09/905,172

Filed:

07/13/2001

Title:

ETCH PATTERN DEFINITION USING A CVD ORGANIC LAYER AS AN

ANTI-REFLECTION COATING AND HARDMASK

Art Unit:

1765

Examiner:

Deo, Duy Vu Nguyen

Docket No.:

004227USA02/ETCH/SILICON

VIA FACSIMILE 703-872-9310 Mail Stop Non Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE

Sir:

Responsive to the Office Action mailed November 14, 2003 in the above matter (the 3-month period for reply extended to February 17, 2004 due to the PTO holiday closing on 2/16/04), Applicants submit the following amendment and remarks: